

# The effects of electron irradiation on the current-voltage and capacitance-voltage measurements of Sn/p-GaAs/Au diodes

Songül Duman<sup>a,\*</sup>, Fikriye Şeyma Kaya<sup>b</sup>, Hülya Doğan<sup>c</sup>, Güven Turgut<sup>a</sup>, Yılmaz Şahin<sup>d</sup>

<sup>a</sup> Department of Basic Sciences, Science Faculty, Erzurum Technical University, 25050, Erzurum, Turkey

<sup>b</sup> Department of Physics, Science Faculty, Ataturk University, 25240, Erzurum, Turkey

<sup>c</sup> Department of Electrical-Electronics Engineering, Sivas Cumhuriyet University, 58140, Sivas, Turkey

<sup>d</sup> Health Services Vocational School, Ataturk University, 25240, Erzurum, Turkey

## ARTICLE INFO

### Keywords:

GaAs  
Diode  
Electron irradiation  
Seri resistance  
Barrier height  
III-V semiconductor

## ABSTRACT

In this study 11 (eleven) Sn/p-GaAs/Au diodes were identically fabricated. Au and Sn metals were used in order to fabricate the ohmic and rectifier contacts, respectively. The effect of electron irradiation of high electron energy of 6, 12, 15 and 18 MeV and low electron fluence of  $1 \times 10^{12}$  electrons/cm<sup>2</sup> on the various parameters such as barrier height (BH), ideality factor (IF), series resistance ( $R_s$ ), and rectification ratio (RR), acceptor concentration ( $N_a$ ), diffusion potential ( $V_d$ ) obtained from current-voltage ( $I$ - $V$ ) and capacitance-voltage ( $C$ - $V$ ) characteristics of Sn/p-GaAs/Au diodes was evaluated. The BH value of one (D2) of the unirradiated 11 Sn/p-GaAs/Au diodes was calculated as 0.82 eV, 0.86 eV and 0.94 eV from  $\ln(I)$ - $V$  characteristics according to the thermionic emission (TE) theory, modified Norde's functions, and  $C$ - $V$  characteristics, respectively. The BH values calculated  $\ln(I)$ - $V$  and Norde's functions were found to be very close to each other. The values of RR, IF, and BH of D2 diode calculated from  $\ln(I)$ - $V$  according to TE theory were calculated as  $1 \times 10^6$ , 1.09 and 0.82 eV,  $1 \times 10^6$ , 1.06 and 0.81 eV,  $1 \times 10^6$ , 1.09 and 0.82 eV,  $1 \times 10^6$ , 1.12 and 0.83 eV,  $1 \times 10^6$ , 1.13 and 0.82 eV for before and after 6, 12, 15 and 18 MeV electron irradiation, respectively. The  $R_s$  value of unirradiated and 6, 12, 15 and 18 MeV electron irradiated D2 diode was calculated from Norde's function was calculated 29, 30, 30, 27, and 26  $\Omega$ , respectively. Since these parameters remain nearly unchanged after electron irradiation, it can be said that electron radiation has no significant effect on  $\ln(I)$ - $V$  characteristics and the Sn/p-GaAs/Au diodes are insensitive to high-energy electron irradiation.

## 1. Introduction

Semiconductor based devices communicate with each other through metal/semiconductor (M/S) contacts in electronic circuits (Coskun et al., 2006). Therefore, it is important to determine how the contact parameters change with high-energy electron radiation. In a radiation environment, when semiconductor devices are exposed to electrons, neutrons, proton, ions, <sup>60</sup>Co  $\gamma$ -ray, and alpha particle, defects and damages may occur in semiconductor devices (Karatas et al., 2005). High-energy particles penetrate the interface and low-energy particles cause severe lattice damage in the form of interstitials, vacancies and defect complexes at the near interface of the device (Dharmarasu et al., 1998). These defects and damages can cause the performance of the semiconductor device to decrease.

Gallium arsenide (GaAs)-based devices have some advantages over

Si-based devices for high-speed and high-power applications due to the high electron mobility in GaAs, high carrier mobility, direct band gap of 1.42 eV which is nearly ideal for single junction solar cells, low power consumption, the higher breakdown field, chemical inertness, mechanical stability and the availability of semi-insulating GaAs substrates (Ye et al., 2003; Lu et al. 2006; Soylu et al., 2011).

GaAs, CdTe, InP, GaN, SiC semiconductor materials offer higher radiation tolerance against  $\gamma$ -rays, electrons, protons, and neutrons and can work in harsh environments over extended durations as compared to Si or Ge (Dixit and Sharma, 2020). Therefore GaAs is very desirable for space applications thanks to the high absorption coefficient of GaAs (Rao et al., 2010).

Many studies have been conducted to understand the effect of radiation on the electrical properties of metal/GaAs diodes (Karatas et al., 2005; Dharmarasu et al. 1998; Rao et al. 2010; Lowe et al., 1977; Ashok

\* Corresponding author.

E-mail address: [songul.duman@erzurum.edu.tr](mailto:songul.duman@erzurum.edu.tr) (S. Duman).

<https://doi.org/10.1016/j.radphyschem.2022.109992>

Received 13 July 2021; Received in revised form 20 December 2021; Accepted 22 January 2022

Available online 25 January 2022

0969-806X/© 2022 Elsevier Ltd. All rights reserved.

et al., 1978; Jayavel et al. 1999, 2003; Hullavarad et al. 1999). Protons and electrons irradiated GaAs solar cells showed a greater resistance to radiation than Si solar cells (Lowe et al., 1977). Ashok et al. (1978) reported that the GaAs metal/insulator/semiconductor (MIS) diodes are insensitive to  $\gamma$ -irradiation, while neutron irradiation changed current-voltage ( $I$ - $V$ ) characteristics significantly with little free carrier compensation. While  $^{60}\text{Co}$   $\gamma$ -ray irradiation caused an increase in the barrier height (BH) calculated from capacitance-voltage ( $C$ - $V$ ) measurements, BH obtained from  $\ln(I)$ - $V$  measurements remained approximately constant for the Au/ $n$ -GaAs diode (Karatas et al., 2005). The Au/ $n$ -GaAs diodes were irradiated with high energy of 70 MeV carbon ions with various ion fluences of  $1 \times 10^{11}$ ,  $1 \times 10^{12}$  and  $1 \times 10^{13}$  ions/cm<sup>2</sup> and  $I$ - $V$  and  $C$ - $V$  characteristics of were analysed. The reverse leakage current increased with increasing ion fluence (Jayavel et al., 1999).

Jayavel et al. (2002) found that the BH of Ni/ $n$ -GaAs decreased, the ideality factor (IF) deviated from the ideal behavior, the reverse leakage current increased with increasing proton fluences. The effect of high energy nitrogen ion irradiated  $n$ -GaAs diode was investigated using deep level transient spectroscopy (Jayavel et al., 2003).

Dharmarasu et al. (1998) reported an increase in reverse bias current, a decrease in BH and an increase in the series resistance value ( $R_s$ ) of Pd/ $n$ -GaAs diode with low energy proton irradiation fluence. The high reverse bias current for higher proton fluence is likely due to irradiation-induced defects that cause tunneling at the interface across the barrier (Dharmarasu et al., 1998). Only minor changes in GaAs solar cell parameters were observed up to an electron dose of 100 kGy, with good tolerance for electrons of 8 MeV energies (Rao et al., 2010).

In this study, Au has selected as ohmic contact metal and Sn selected to form Schottky contact. In the previous studies, Deniz et al. (2014) and Vandenbroucke et al. (1987) used Au metal to form ohmic contact. The detailed information on the  $I$ - $V$  characteristics of metal/ $n$ -GaAs diodes has been documented in the literature (Ozavci et al., 2013; Yildirim et al., 2009; Korucu et al., 2013; Dharmarasu et al., 1998; Jayavel et al., 2002). But, very few reports are available about the Schottky diode properties of metal/ $p$ -GaAs (Soylu et al., 2011; Mazari et al., 2002; Myburg et al., 1998; Deniz et al., 2014; Vandenbroucke et al., 1987). To the best of authors knowledge, there is no experimental data available on the  $I$ - $V$  measurements of Sn/ $p$ -GaAs/Au Schottky diode in literature. Also, there is no study on the effects of electron irradiation on the  $I$ - $V$  and  $C$ - $V$  characteristics of the Sn/ $p$ -GaAs/Au diodes. Therefore in this study, the aim is to fabricate Sn/ $p$ -GaAs/Au diodes with high BH and low IF and analyze the effects of irradiation with electron energies of 6, 12, 15, 18 MeV with a constant fluence of  $10^{12}$  electrons/cm<sup>2</sup> on  $I$ - $V$  and  $C$ - $V$  characteristics. Hence, the data presented in this study is believed to contribute to the existing data on the radiation hardness of GaAs based devices.

## 2. Experimental procedure

First  $p$ -GaAs sample with a thickness of 375  $\mu\text{m}$  was cleaned with trichloroethylene, acetone and methanol for 5 min, to remove surface impurity layer and improve the quality of device, respectively. Then it was rinsed with de-ionized water, etched in  $5\text{H}_2\text{SO}_4 + \text{H}_2\text{O}_2 + \text{H}_2\text{O}$  solution for 60 min. Lastly, it was rinsed with deionized water and dried with high purity nitrogen ( $\text{N}_2$ ). To form ohmic contact, gold (Au) metal was evaporated on the back of  $p$ -GaAs sample using the thermal evaporation method at  $10^{-6}$  Torr and annealed at 450  $^\circ\text{C}$  for 3 min in a pure  $\text{N}_2$  atmosphere in a quartz tubes. Then, to form the rectifier (Schottky) contact, tin (Sn) of 99.99% purity on the other surface of  $p$ -GaAs sample was evaporated with a metal shadow mask of 1.00 mm diameter at a pressure of  $10^{-6}$  Torr. The thickness of the Sn film was 1000  $\text{\AA}$ . Thus the 11 Sn/ $p$ -GaAs/Au diodes (Schottky contacts) which was labeled as D1, D2, ...and D11 were fabricated on the same  $p$ -GaAs semiconductor substrate by evaporation of Sn. Later,  $I$ - $V$  measurements of all diodes were taken before the Sn/ $p$ -GaAs/Au was irradiated. Then, the diodes

were exposed to 6 MeV electron irradiation at room temperature and  $I$ - $V$  measurements of all diodes were taken. This process was repeated in electron irradiation with energies of 12, 15 and 18 MeV, respectively. The electron fluence for each electron irradiation is  $10^{12}$  electrons/cm<sup>2</sup>. Also, during the electron irradiation process no bias voltage was applied to the Sn/ $p$ -GaAs/Au diodes. A Siemens-Primus linear electron accelerator which allowed to accelerate the electrons up to 21 MeV energy was used for electron irradiation. The  $I$ - $V$  and  $C$ - $V$  measurements were carried out using a Keithley 2400 Picoammeter/Voltage source and a HP 4192 A LF Impedance analyzer, in dark and at room temperature, respectively. The schematic diagram of Sn/ $p$ -GaAs/Au diode is illustrated in Fig. 1.

## 3. Results and discussion

Schottky diodes made from high mobility semiconductors possess the  $I$ - $V$  characteristics given by the thermionic-emission (TE) theory, provided the forward bias is not too large. According to TE theory,  $I$ - $V$  characteristics can be defined as (Rhoderick and Williams, 1988);

$$I = I_0 \left[ \exp\left(\frac{qV}{kT}\right) - 1 \right] \quad (1)$$

In practice diodes never satisfy the ideal Eq. (1) exactly, but can be more closely described by the modified equation

$$I = I_0 \exp\left(\frac{qV}{nkT}\right) \left[ 1 - \exp\left(-\frac{qV}{kT}\right) \right] \quad (2)$$

where IF ( $n$ ) is approximately independent of  $V$  and is greater than unity. For values of  $V$  greater than  $3kT/q$ , Eq. (1) can be written

$$I = I_0 \exp\left(\frac{qV}{nkT}\right) \quad (3)$$

where  $I_0$  is the reverse saturation current and it is defined by,

$$I_0 = AA^* T^2 \left( \exp\left(-\frac{q\Phi_b}{kT}\right) \right) \quad (4)$$

where  $V$  is the bias voltage,  $A$  is the diode area (0,00785 cm<sup>2</sup>),  $A^*$  is the Richardson constant,  $T$  is temperature in Kelvin,  $k$  is Boltzmann constant ( $8,625 \times 10^{-5}$  eV K<sup>-1</sup>),  $q$  is electronic charge ( $1,6 \times 10^{-19}$  C),  $\Phi_b$  is the zero bias apparent BH, respectively.

From Eq. (3), the value of  $n$  is determined as follows:

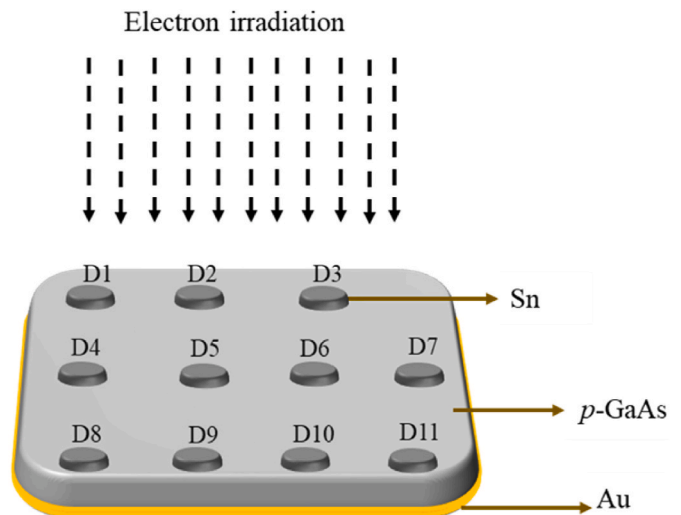


Fig. 1. Schematic diagram of Sn/ $p$ -GaAs/Au diodes.

$$n = \frac{q}{kT} \left( \frac{dV}{d(\ln I)} \right) \quad (5)$$

The  $\ln(I)$ - $V$  characteristics of the unirradiated 11 Sn/p-GaAs/Au diodes are illustrated in Fig. 2. All diodes show a good rectifying properties with relatively low reverse bias current.

Fig. 3 shows  $\ln(I)$ - $V$  characteristics of the unirradiated and electron (energy of 6, 12, 15, and 18 MeV) irradiated Sn/p-GaAs/Au diodes with a relatively low-fluence of  $10^{12}$  electrons/cm<sup>2</sup>.

Coskun et al. (2006) investigated the effects of high-energy (6, 9, 12 MeV) and relatively low-dose ( $3 \times 10^{12}$  electrons/cm<sup>2</sup>) electron irradiation on the parameters of  $n$ -ZnO-based ohmic and Schottky contacts. The IF of the Au/ $n$ -ZnO diode increased and BH decreased with increasing electron energy. It was concluded that the atoms of the contact elements diffused into the semiconductor material and thus turning the rectifying character to the ohmic behavior with the influence of radiation-matter interaction (Coskun et al., 2006). Krishnan et al. (2008) investigated the effect electron irradiation of 8 MeV energy up to a dose of about 100 kGy (equivalent to a fluence of  $3.02 \times 10^{13}$  electrons/cm<sup>2</sup>) on the  $I$ - $V$  characteristics of Al/p-Si Schottky diodes. A decrease in the BH and an increase in the IF were observed up to a dose of about 25 kGy. It was reported that the degradation in the diode properties may be due to the introduction of radiation-induced interfacial defects via displacement damage. (Krishnan et al., 2008). Cinar et al. (2010) studied the effect of electron irradiation with various energies (6, 12 and 15 MeV) with a constant fluence of  $10^{12}$  electrons/cm<sup>2</sup> on  $I$ - $V$  of Au/Ni/6H-SiC and Au/Ni/4H-SiC Schottky diodes. They found that the electrical characteristics of Au/Ni/6H-SiC and Au/Ni/4H-SiC diodes are sensitive to electron irradiation. Aydogan and Turut (2011) investigated the effect of 12 MeV electron irradiation with fluency of  $10^{12}$  electrons/cm<sup>2</sup> on  $I$ - $V$  characteristics of Au/Carmine/p-Si/Al. The IF and  $R_s$  values increased and the reverse bias current and capacitance decreased with 12 MeV electron irradiation. This was attributed to decrease in net ionized dopant concentration with electron irradiation.

In the present study, as seen in Fig. 3, there is no significant change in the  $\ln(I)$ - $V$  characteristics of the Sn/p-GaAs/Au diodes after electron

irradiation. Using TE theory, the BH and IF values of Sn/p-GaAs/Au diodes were calculated from the y-axis intercept and slope of the linear region of the experimental forward bias  $\ln(I)$ - $V$  data for each electron irradiation, respectively.

The IF and BH values of unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes are given in Tables 1 and 2, respectively. The IF and BH values of the Sn/p-GaAs/Au diodes varied from 1.07 to 1.35 and 0.70–0.82 eV before irradiation, 1.06 to 1.36 and 0.69–0.81 eV under 6 MeV irradiation, 1.09 to 1.39 and 0.69–0.82 eV under 12 MeV irradiation, 1.10 to 1.34 and 0.70–0.83 eV under 15 MeV irradiation, and 1.11 to 1.35 and 0.70–0.82 eV under 18 MeV irradiation, respectively. The calculated values of BH are the same for unirradiated some diodes. The average IF  $n$  and standard deviation values ( $\sigma$ ) were determined to be 1.17 and 0.092 before irradiation, 1.18 and 0.097 under 6 MeV irradiation, 1.20 and 0.100 under 12 MeV irradiation, 1.20 and 0.082 under 15 MeV irradiation, 1.20 and 0.083 under 18 MeV irradiation, respectively. The average BH  $\phi$  and standard deviation values ( $\sigma$ ) were determined to be 0.78 and 0.038 before irradiation, 0.78 and 0.044 under 6 MeV irradiation, 0.78 and 0.044 under 12 MeV irradiation, 0.79 and 0.042 under 15 MeV irradiation, 0.79 and 0.042 under 18 MeV irradiation, respectively. The Sn/p-GaAs/Au diodes have a BH and a low leakage current. Thus, it can be said that the IF and BH values almost remain constant after irradiation. The calculated values of IF ( $n < 1.4$ ) reveal mostly thermionic emission to be the dominant transport mechanisms for all diodes.

The BH and IF values of various diodes fabricated using GaAs semiconductor in the literature were given in Table 3.

A quality diode should have a high BH, a low IF, a low leakage current, a low  $R_s$ , and a high rectification ratio ( $RR = I_{\text{forward}}/I_{\text{reverse}}$ ). For an ideal Schottky diode, IF has a value of 1.0. The IF values have changed between 1.07 and 1.10 for 6 Sn/p-GaAs/Au diodes as seen in Table 3. These values are lower than the values of 1.41 and 1.14, which was found by Soylu et al. (2011) and Vandenbroucke et al. (1987), respectively. The mean value BH of 0.78 for the unirradiated Sn/p-GaAs/Au diodes is higher than BH values reported by Soylu et al. (2011), Mazari et al. (2002), Myburg et al. (1998), Deniz et al. (2014), Vandenbroucke et al. (1987) for some metal/p-GaAs diodes. The Sn/p-GaAs/Au diodes have RR between about  $10^4$  and  $10^6$  at  $\pm 1.0$  V and a RR as high as  $10^5$  was achieved for the 6 Sn/p-GaAs/Au diodes (Table 4). The RR value for almost all diodes hasn't changed after electron irradiation at different energies.

The forward bias  $\ln(I)$ - $V$  characteristics of the Sn/p-GaAs/Au diodes deviate from linearity due to the effect of  $R_s$  at large applied voltages and thus high power dissipation occurs.  $R_s$  is influenced by the presence of the interface layer between the metal and the semiconductor, low quality of ohmic contact, organic impurities, interfacial states and bulk resistance of the semiconductor (Nicollian and Brews, 1982; Lapa et al. 2020).

Norde's (1979) function modified by Bohlin (1986) can be used to determine the  $\Phi_b$  and  $R_s$  values of the Sn/p-GaAs/Au diodes. They are given as follows:

$$F(V) = \frac{V_0}{\gamma} - \frac{kT}{q} \ln \left( \frac{I(V)}{AA^*T^2} \right) \quad (6)$$

Here, the value of  $\gamma$  ( $\gamma = 2$ ) should be selected as a number greater than the value of  $n$  obtained from the  $\ln(I) - V$  characteristics.

$$\Phi_b = F(V_{\min}) + \left[ \left( \frac{\gamma - n}{n} \right) \right] \left[ \frac{V_{\min}}{\gamma} - \frac{kT}{q} \right] \quad (7)$$

$$R_s = \frac{(\gamma - n)kT}{qI_{\min}} \quad (8)$$

Fig. 4 shows the  $F(V)$ - $V$  plots of the unirradiated Sn/p-GaAs/Au diodes. Fig. 5 shows the  $F(V) - V$  plot of one (D2) of the unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes.

BH values determined from Eq. (7) and  $R_s$  values determined from

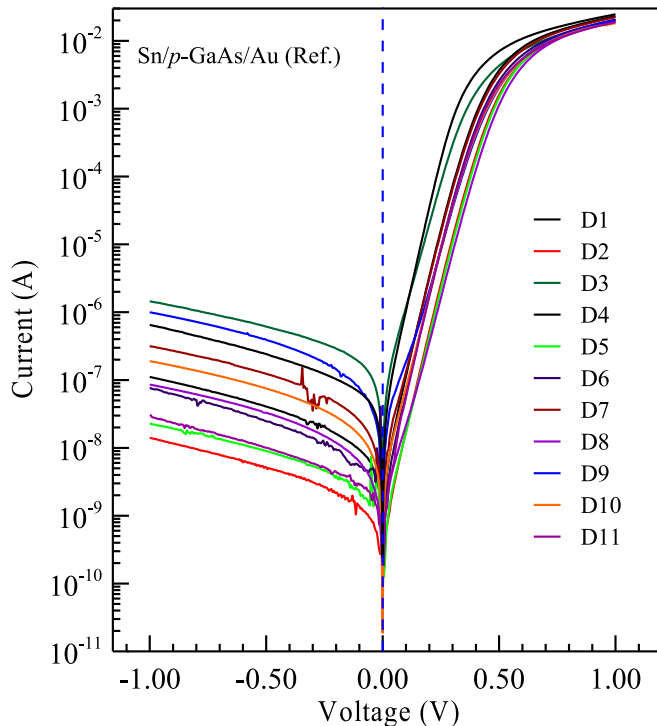


Fig. 2. The  $\ln(I)$ - $V$  characteristics of the unirradiated 11 Sn/p-GaAs/Au diodes (labeled as D1, D2, ...and D11).

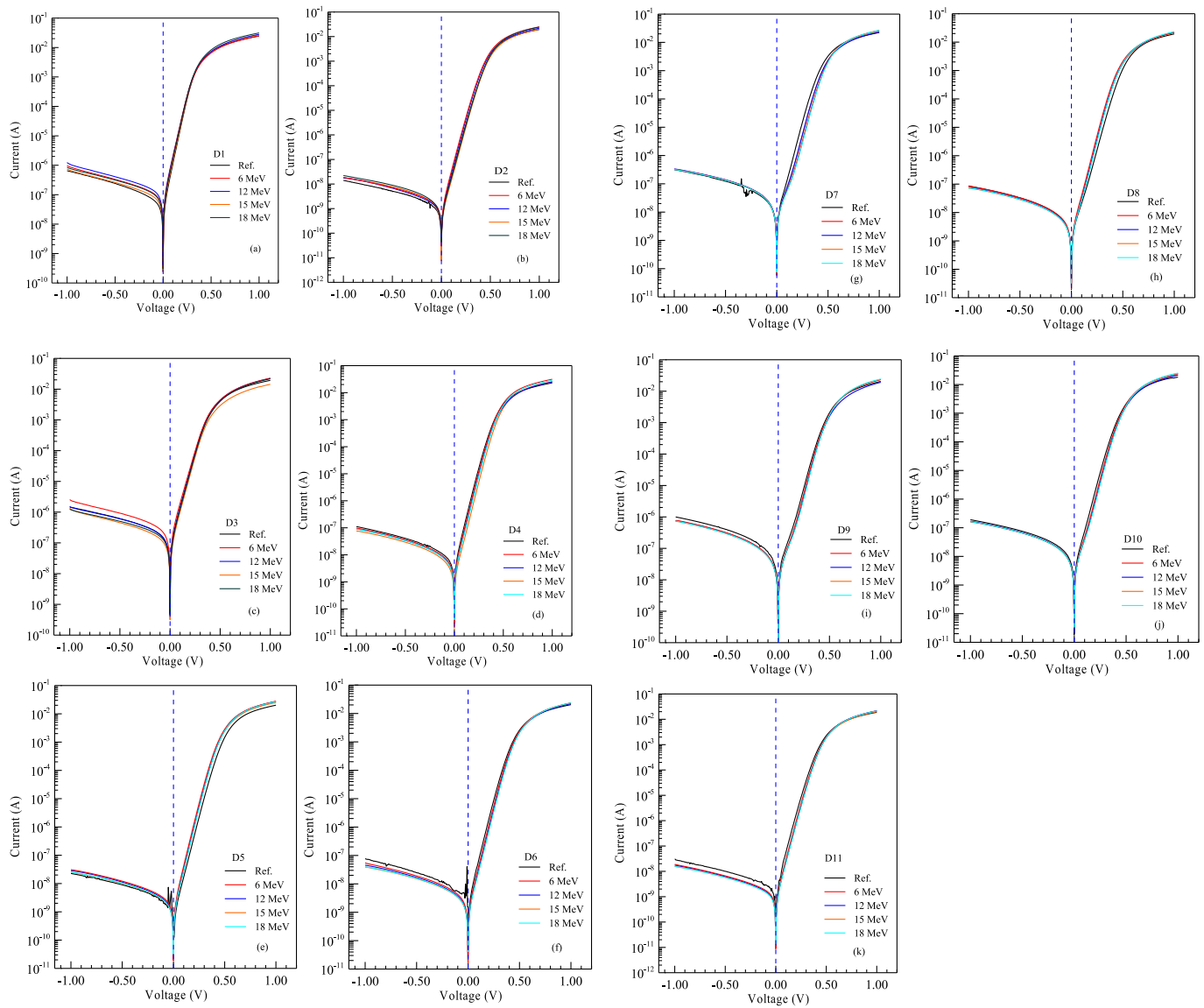


Fig. 3. (a)–(k). The  $\ln(I)$ – $V$  characteristics of unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes.

Table 1

The IF values calculated from  $\ln(I)$ – $V$  according to TE theory of Sn/p-GaAs/Au diodes before irradiation and under 6, 12, 15, and 18 MeV electron irradiation, respectively.

IF (n)					
Diode number	Before irradiation	6 MeV irradiation	12 MeV irradiation	15 MeV irradiation	18 MeV irradiation
D1	1.07	1.08	1.11	1.10	1.11
D2	1.09	1.06	1.09	1.12	1.13
D3	1.26	1.30	1.39	1.33	1.35
D4	1.10	1.12	1.16	1.17	1.16
D5	1.10	1.09	1.11	1.15	1.15
D6	1.10	1.12	1.15	1.16	1.16
D7	1.21	1.25	1.24	1.26	1.26
D8	1.23	1.22	1.20	1.20	1.19
D9	1.35	1.36	1.36	1.34	1.34
D10	1.22	1.22	1.23	1.22	1.22
D11	1.10	1.16	1.12	1.15	1.13
$n$	1.17	1.18	1.20	1.20	1.20
$\sigma$	0.092	0.097	0.100	0.082	0.083

Table 2

The BH values calculated from  $\ln(I)$ – $V$  according to TE theory of Sn/p-GaAs/Au diodes before irradiation and under 6, 12, 15, and 18 MeV electron irradiation, respectively.

$\Phi_b$ (eV)					
Diode number	Before irradiation	6 MeV irradiation	12 MeV irradiation	15 MeV irradiation	18 MeV irradiation
D1	0.72	0.71	0.70	0.71	0.71
D2	0.82	0.81	0.82	0.83	0.82
D3	0.70	0.69	0.69	0.70	0.70
D4	0.78	0.78	0.79	0.80	0.79
D5	0.82	0.80	0.81	0.81	0.81
D6	0.79	0.80	0.80	0.81	0.81
D7	0.77	0.80	0.79	0.79	0.80
D8	0.80	0.79	0.80	0.81	0.81
D9	0.76	0.77	0.77	0.78	0.78
D10	0.78	0.79	0.80	0.80	0.80
D11	0.80	0.80	0.81	0.81	0.82
$\Phi$	0.78	0.78	0.78	0.79	0.79
$\sigma$	0.038	0.044	0.044	0.042	0.042

**Table 3**

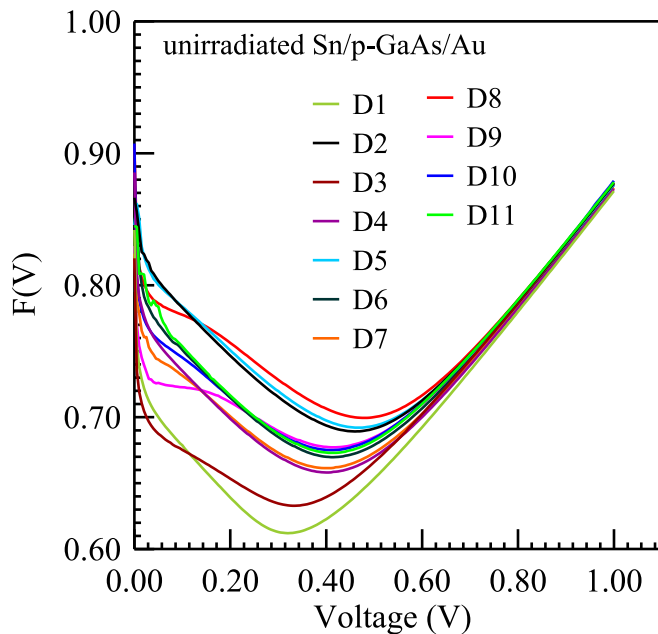
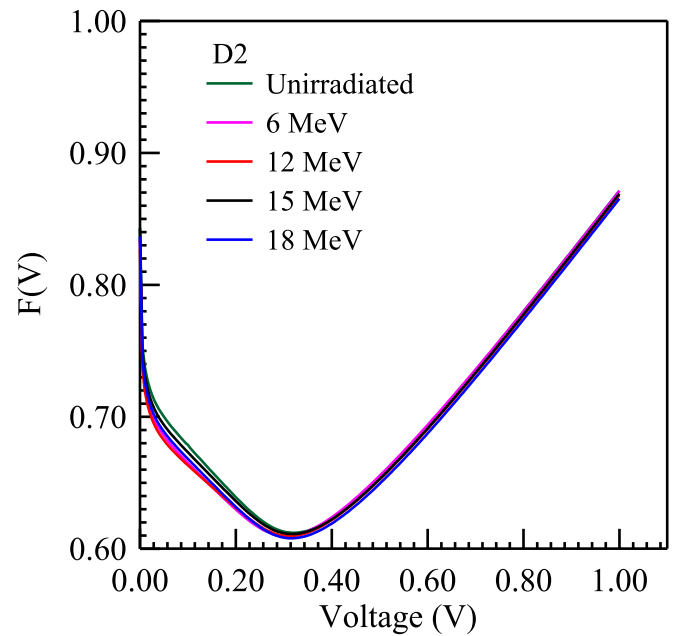
Experimental IF and BH values reported for various metal/p-GaAs diodes in the literature.

Diode	IF	BH (eV)	Ref.
Sn/p-GaAs	1.17 (average value for eleven diodes)	0.78 eV (average value for eleven diodes)	Present work
Al/p-GaAs	1.41	0.68	Soylu et al. (2011)
Al/p-GaAs	–	0.67	Mazari et al. (2002)
Ru/p-GaAs	–	0.60	Myburg et al. (1998)
Ga/p-GaAs	–	0.83	Myburg et al. (1998)
Al/p-GaAs	–	0.67	Myburg et al. (1998)
Au/Pd/p-GaAs	–	0.68	Deniz et al. (2014)
Al/p-GaAs	1.14	0.59	Vandenbroucke et al. (1987)

**Table 4**

The RR values of Sn/p-GaAs/Au diodes the before and after 6, 12, 15, and 18 MeV electron irradiation.

Diode number	RR (at $\pm 1$ V)				
	Before irradiation	6 MeV irradiation	12 MeV irradiation	15 MeV irradiation	18 MeV irradiation
1	$4 \times 10^4$	$3 \times 10^4$	$2 \times 10^4$	$4 \times 10^4$	$4 \times 10^4$
2	$1 \times 10^6$	$1 \times 10^6$	$1 \times 10^6$	$1 \times 10^6$	$1 \times 10^6$
3	$1 \times 10^4$	$9 \times 10^3$	$1 \times 10^4$	$1 \times 10^4$	$2 \times 10^4$
4	$2 \times 10^5$	$3 \times 10^5$	$3 \times 10^5$	$3 \times 10^5$	$3 \times 10^5$
5	$9 \times 10^5$	$9 \times 10^5$	$1 \times 10^6$	$1 \times 10^6$	$1 \times 10^6$
6	$3 \times 10^5$	$4 \times 10^5$	$5 \times 10^5$	$6 \times 10^5$	$6 \times 10^5$
7	$7 \times 10^4$	$8 \times 10^4$	$7 \times 10^4$	$7 \times 10^4$	$8 \times 10^4$
8	$2 \times 10^5$	$3 \times 10^5$	$3 \times 10^5$	$3 \times 10^5$	$3 \times 10^5$
9	$2 \times 10^4$	$3 \times 10^4$	$3 \times 10^4$	$3 \times 10^4$	$3 \times 10^4$
10	$1 \times 10^5$	$1 \times 10^5$	$1 \times 10^5$	$1 \times 10^5$	$1 \times 10^5$
11	$6 \times 10^5$	$1 \times 10^6$	$1 \times 10^6$	$1 \times 10^6$	$1 \times 10^6$

**Fig. 4.** The  $F(V)$ – $V$  plots of the unirradiated 11 Sn/p-GaAs/Au diodes.**Fig. 5.**  $F(V)$  –  $V$  plots of one (D2) of the unirradiated and electron irradiated Sn/p-GaAs/Au diodes.

Eq. (8) are presented in Tables 5 and 6, respectively. The value of  $R_s$  for all diodes is small. This shows a low resistivity ohmic contact between p-GaAs and Au. The BH and  $R_s$  values of eleven Sn/p-GaAs/Au diodes varied from 0.72 to 0.86 eV and 23–45  $\Omega$  before irradiation, 0.72–0.85 eV and 22–36  $\Omega$  under 6 MeV irradiation, 0.71–0.84 eV and 23–33  $\Omega$  under 12 MeV irradiation, 0.71–0.85 eV and 21–42  $\Omega$  under 15 MeV irradiation, 0.70–0.85 eV and 13–45  $\Omega$  under 18 MeV irradiation, respectively. The average BH and standard deviation values ( $\sigma$ ) were determined to be 0.80 and 0.048 before irradiation, 0.79 and 0.045 under 6 MeV irradiation, 0.79 and 0.047 under 12 MeV irradiation, 0.80 and 0.044 under 15 MeV irradiation, 0.79 and 0.045 under 18 MeV irradiation, respectively. The average series resistance  $R_s$  and standard deviation values ( $\sigma$ ) were determined to be 33 and 6.5  $\Omega$  before irradiation, 29 and 5.0  $\Omega$  under 6 MeV irradiation, 29 and 3.4  $\Omega$  under 12 MeV irradiation, 28 and 6.2  $\Omega$  under 15 MeV irradiation, 25 and 8.4  $\Omega$  under 18 MeV irradiation, respectively. The BH values obtained from Norde's functions are in good agreement with the values obtained from the  $\ln(I)$ – $V$ .

Figs. 6 and 7 show the  $C$ – $V$  and reverse bias  $1/C^2$ – $V$  characteristics of one (D2) of the unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes at a frequency of 500 kHz. As seen in Fig. 6, a very slight decrease in the capacitance value was observed after electron irradiation between 6 and 18 MeV. Thus, it can be concluded that electron irradiation has not contributed significantly to the increase of deep level defects [7].

The values of acceptor concentration ( $N_a$ ) and diffusion potential ( $V_d$ ) were obtained from the slope and extrapolation of the linear part of the  $C^{-2}$ – $V$  curves to the voltage axis for the before and after electron irradiation. The  $N_a$ ,  $V_d$  and BH values of unirradiated and electron irradiated Sn/p-GaAs/Au (D2) are given in Table 7. There is a slight decrease in the  $N_a$  value due to the trapping effect of the irradiation induced defects. The value of  $V_d$  and BH remains almost unchanged after irradiation because there is no significant change in the depletion region of the Sn/p-GaAs/Au diode.

#### 4. Conclusion

In this study, the Sn/p-GaAs/Au diodes of high BH were fabricated. The effect of high-energy electron irradiation on  $I$ – $V$  and  $C$ – $V$  characteristics of the 11 Sn/p-GaAs/Au diodes was evaluated. It wasn't



**Table 5**

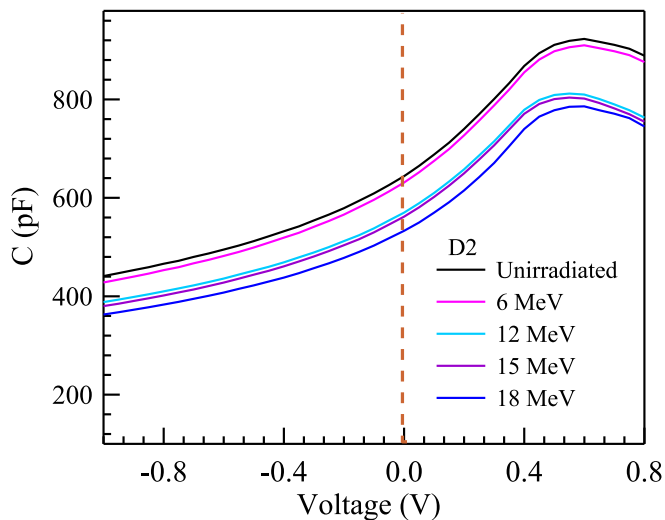
The BH values obtained calculated from modified Norde's functions for the unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes.

$\Phi_b$ (eV)					
Diode number	Before irradiation	6 MeV irradiation	12 MeV irradiation	15 MeV irradiation	18 MeV irradiation
1	0.73	0.72	0.71	0.72	0.70
2	0.86	0.85	0.84	0.85	0.85
3	0.72	0.70	0.70	0.71	0.74
4	0.80	0.80	0.80	0.81	0.79
5	0.86	0.83	0.83	0.82	0.82
6	0.82	0.82	0.82	0.82	0.84
7	0.77	0.81	0.79	0.79	0.82
8	0.83	0.80	0.81	0.82	0.78
9	0.76	0.77	0.78	0.78	0.81
10	0.79	0.80	0.81	0.81	0.75
11	0.82	0.81	0.83	0.83	0.78
$\phi$	0.80	0.79	0.79	0.80	0.79
$\sigma$	0.048	0.045	0.047	0.044	0.045

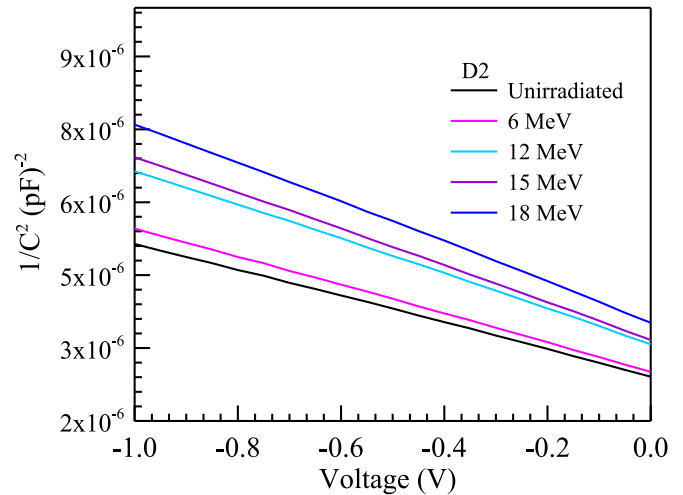
**Table 6**

The BH values obtained calculated from modified Norde's functions for the unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes.

$R_s$ ( $\Omega$ )					
Diode number	Before irradiation	6 MeV irradiation	12 MeV irradiation	15 MeV irradiation	18 MeV irradiation
1	23	28	24	21	16
2	29	30	30	27	26
3	30	33	29	42	45
4	28	22	26	22	21
5	33	28	23	24	24
6	36	31	26	22	30
7	31	19	29	23	19
8	28	32	33	31	24
9	35	30	33	30	27
10	42	25	30	31	13
11	45	36	31	31	25
$R_s$	33	29	29	28	25
$\sigma$	6.5	5.0	3.4	6.2	8.4

**Fig. 6.** The C-V characteristics of one (D2) of the unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes at a frequency of 500 kHz.

observed very significant change in the  $I$ - $V$  characteristics of Sn/p-GaAs/Au diodes under the electron irradiation. The capacitance value of electron irradiated diode slightly decreased. The BH, IF, and  $R_s$  values of Sn/p-GaAs/Au remained nearly constant and the diodes were insensitive to electron irradiation. These results confirm the Sn/p-GaAs/Au diodes

**Fig. 7.** The reverse bias  $1/C^2$ - $V$  characteristics of one (D2) of the unirradiated and electron irradiated 11 Sn/p-GaAs/Au diodes at a frequency of 500 kHz.**Table 7**The acceptor concentration ( $N_a$ ), diffusion potential ( $V_d$ ) and BH values of one (D2) of the unirradiated and electron irradiated 11 Sn/p-GaAs/Au calculated from  $C^{-2}$ - $V$  characteristics.

	Acceptor concentration ( $N_a$ )	$V_d$ (eV)	BH (eV)
Unirradiated	$6.5 \times 10^{16}$	0.89	0.94
6 MeV	$6.0 \times 10^{16}$	0.86	0.91
12 MeV	$5.0 \times 10^{16}$	0.87	0.93
15 MeV	$4.7 \times 10^{16}$	0.85	0.90
18 MeV	$4.3 \times 10^{16}$	0.87	0.93

could be used in space applications as the electron irradiation-resistant contacts.

#### CRediT authorship contribution statement

**Songül Duman:** Conceptualization, Investigation, Writing – original draft, Writing – review & editing. **Fikriye Şeyma Kaya:** Conceptualization, Investigation, Writing – original draft, Writing – review & editing. **Hülya Doğan:** Writing – original draft, Writing – review & editing. **Güven Turgut:** Investigation. **Yılmaz Şahin:** Investigation.

#### Declaration of competing interest

The authors declare that they have no known competing financial interests or personal relationships that could have appeared to influence

the work reported in this paper.

## References

- Ashok, S., Borrego, J.M., Gutmann, R.J., 1978. Radiation effects in GAAS MIS schottky diodes. *IEEE Trans. Nucl. Sci.* 25, 1473–1478. <https://doi.org/10.1109/TNS.1978.4329556>.
- Aydogan, S., Turut, A., 2011. Influence of 12 MeV electron irradiation on the electrical and photovoltaic properties of Schottky type solar cell based on Carmine. *Radiat. Phys. Chem.* 80, 869–875. <https://doi.org/10.1016/j.radphyschem.2011.03.019>.
- Bohlin, K.E., 1986. Generalized Norde plot including determination of the ideality factor. *J. Appl. Phys.* 60, 1223–1224. <https://doi.org/10.1063/1.337372>.
- Cinar, K., Coskun, C., Aydogan, S., Asil, H., Gur, E., 2010. The effect of the electron irradiation on the series resistance of Au/Ni/6H-SiC and Au/Ni/4H-SiC Schottky contacts. *Nucl. Instrum. Methods Phys. Res. B* 268, 616–621. <https://doi.org/10.1016/j.nimb.2009.12.019>.
- Coskun, C., Gedik, N., Balci, E., 2006. The effect of high-energy electron irradiation on ZnO-based ohmic and Schottky contacts. *Semicond. Sci. Technol.* 21, 1656–1660. <https://doi.org/10.1088/0268-1242/21/12/026>.
- Dharmarasu, N., Arulkumaran, S., Sumathi, R.R., Jayavel, P., Kumar, J., Magudapathy, P., Nair, K.G.M., 1998. Low energy proton irradiation induced interface defects on Pd/n-GaAs Schottky diodes and its characteristics. *Nucl. Instrum. Methods Phys. Res. B* 140, 119–123. [https://doi.org/10.1016/S0168-583X\(98\)00003-2](https://doi.org/10.1016/S0168-583X(98)00003-2).
- Deniz, A.R., Çaldıran, Z., Metin, Ö., Can, H., Meral, K., Aydogan, S., 2014. Schottky diode performance of an Au/Pd/GaAs device fabricated by deposition of monodisperse palladium nanoparticles over a p-type GaAs substrate. *Mater. Sci. Semicond. Process.* 27, 163–169. <https://doi.org/10.1016/j.mssp.2014.06.022>.
- Dixit, V.K., Sharma, T.K., 2020. Development and deployment of radiation resistant GaAs based PIN photodetectors. *RRCAT Newsletter* 33, 70–78.
- Hullavarad, Shiva S., Bhoraskar, S.V., Kanjilal, D., 1999. Oxygen related defects in high energy ion irradiated GaAs. *Nucl. Instrum. Methods Phys. Res. B* 156, 95–99. [https://doi.org/10.1016/S0168-583X\(99\)00165-2](https://doi.org/10.1016/S0168-583X(99)00165-2).
- Jayavel, P., Udhayasankar, M., Kumar, J., Asokan, K., Kanjilal, D., 1999. Electrical characterisation of high energy  $^{12}\text{C}$  irradiated Au/n-GaAs Schottky Barrier Diodes. *Nucl. Instrum. Methods Phys. Res. B* 156, 110–115. [https://doi.org/10.1016/S0168-583X\(99\)00282-7](https://doi.org/10.1016/S0168-583X(99)00282-7).
- Jayavel, P., Santhakumar, K., Kumar, J., 2002. Studies on the proton irradiation induced defects on Ni/n-GaAs Schottky barrier diodes. *Physica B* 315, 88–95. [https://doi.org/10.1016/S0921-4526\(01\)01104-8](https://doi.org/10.1016/S0921-4526(01)01104-8).
- Jayavel, P., Santhakumar, K., Asoka, K., 2003. Studies on the nitrogen ion irradiation induced defects in n-GaAs by deep level transient spectroscopy. *Nucl. Instrum. Methods Phys. Res. B* 212, 496–500. [https://doi.org/10.1016/S0168-583X\(03\)01746-4](https://doi.org/10.1016/S0168-583X(03)01746-4).
- Karatas, S., Turut, A., Altindal, S., 2005. Effects of  $^{60}\text{Co}$  g-ray irradiation on the electrical characteristics of Au/n-GaAs (MS) structures. *Nucl. Instrum. Methods Phys. Res. A* 555, 260–265. <https://doi.org/10.1016/j.nima.2005.09.017>.
- Korucu, D., Turut, A., Efeoglu, H., 2013. Temperature dependent I–V characteristics of an Au/n-GaAs Schottky diode analyzed using Tung’s model. *Physica B* 414, 35–41. <https://doi.org/10.1016/j.physb.2013.01.010>.
- Krishnan, S., Sanjeev, G., Pattabi, M., 2008. Electron irradiation effects on the Schottky diode characteristics of p-Si. *Nucl. Instrum. Methods Phys. Res. B* 266, 621–624. <https://doi.org/10.1016/j.nimb.2007.11.049>.
- Lapa, H.E., Güçlü, C.S., Aldemir, D.A., Özdemir, A.F., 2020. The evaluation of the current–voltage and capacitance–voltage–frequency measurements of Yb/p-Si Schottky diodes with a high zero-bias barrier height. *Appl. Phys. A* 126, 473. <https://doi.org/10.1007/s00339-020-03662-8>.
- Lowe, L.F., Cappelli, J.R., James, L.W., Moon, R.L., 1977. Radiation Effects on AlGaAs-GaAs Solar Cells Using 0.9–3.0 MeV Protons and 1.0–1.4 MeV Electrons. *Technical Report*.
- Lu, H.-L., Sun, L., Ding, S.-J., Xu, M., Zhang, D.W., Wang, L.-K., 2006. Characterization of atomic-layer-deposited  $\text{Al}_2\text{O}_3/\text{GaAs}$  interface improved by  $\text{NH}_3$  plasma pretreatment. *Appl. Phys. Lett.* 89, 152910. <https://doi.org/10.1063/1.2363145>.
- Mazari, H., Benamara, Z., Bonnaud, O., Olier, R., 2002. Chemical lowering of the interface Fermi level of n and p types GaAs/Al Schottky diodes. *Mater. Sci. Eng. B* 90, 171–175. [https://doi.org/10.1016/S0921-5107\(01\)00935-7](https://doi.org/10.1016/S0921-5107(01)00935-7).
- Myburg, G., Aurret, F.D., Meyer, W.E., Louw, C.W., van Staden, M.J., 1998. Summary of Schottky barrier height data on epitaxially grown n- and p-GaAs. *Thin Solid Films* 325, 181–186. [https://doi.org/10.1016/S0040-6090\(98\)00428-3](https://doi.org/10.1016/S0040-6090(98)00428-3).
- Nicollian, E.H., Brews, J.R., 1982. *MOS (Metal Oxide Semiconductor) Physics and Technology*. Wiley, New York.
- Norde, H., 1979. A modified forward I-V plot for Schottky diodes with high series resistance. *J. Appl. Phys.* 50, 5052–5053. <https://doi.org/10.1063/1.325607>.
- Ozavci, E., Demirezen, S., Aydemir, U., Altindal, S., 2013. A detailed study on current–voltage characteristics of Au/n-GaAs in wide temperature range. *Sensor Actuator Phys.* 194, 259–268. <https://doi.org/10.1016/j.sna.2013.02.018>.
- Rao, A., Krishnan, S., Sajeev, G., Siddappa, K., 2010. Temperature and 8 MeV electron irradiation effects on GaAs solar cells. *Pramana - J. Phys.* 74, 995–1008. <https://doi.org/10.1007/s12043-010-0090-z>.
- Rhoderick, E.H., Williams, R.H., 1988. *Metal-, Semiconductor edn*. Clarendon, Oxford.
- Soylu, M., Yakuphanoglu, F., Farooq, W.A., 2011. The pinch-off effect and inhomogeneous barrier height analysis in Al/p-GaAs Schottky barrier diodes. *Optoelectron. Mater. Rapid Commun.* 5, 135–142. <https://doi.org/10.1016/j.nima.2005.09.017>.
- Vandenbroucke, D.A., Van Meirhaeghe, R.L., Laflere, W.H., Cardon, F., 1987. Sputter-induced damage in Al/n-GaAs and Al/p-GaAs Schottky barriers. *Semicond. Sci. Technol.* 2, 293–298. <https://doi.org/10.1088/0268-1242/2/5/008>.
- Ye, P.D., Wilk, G.D., Yang, B., Kwo, J., Chu, S.N.G., Nakahara, S., Gossmann, H.-J.L., Mannaerts, J.P., Hong, M., Ng, K.K., Bude, J., 2003. GaAs metal–oxide–semiconductor field-effect transistor with nanometer-thin dielectric grown by atomic layer deposition. *Appl. Phys. Lett.* 83, 180–182. <https://doi.org/10.1063/1.1590743>.
- Yildirim, N., Dogan, H., Korkut, H., Turut, A., 2009. Dependence of characteristic diode parameters in Ni/n-GaAs contacts on thermal annealing and sample temperature. *Int. J. Mod. Phys. B* 23, 5237–5249. <https://doi.org/10.1142/S0217979209053564>.